

Appl. No. 09/274,194  
Request for Reconsideration: dated January 27, 2004  
Reply to Final Office Action of September 30, 2003

**Response Under 37 C.F.R. § 1.116  
Expedited Procedure  
Examining Group 1765  
PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of:

John E. LANG

Application No: 09/274,194

Filed: October 16, 2001

For: METHOD OF REMOVING PHOTORESIST  
MATERIAL WITH DIMETHYL SULFOXIDE

) Docket No: LAM2P266

) Group Art Unit: 1765

) Examiner: C. Brown

) January 27, 2004

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**CERTIFICATE OF FACSIMILE**

I hereby certify that this correspondence and the papers referred to herein as attached are being transmitted to the United States Patent and Trademark Office via facsimile to (703) 872-9306, Attn: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on January 27, 2004.

Signed:

*Courtney P. Yaden*  
Courtney P. Yaden

Mail Stop: AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REQUEST FOR RECONSIDERATION**

Dear Sir:

This is in response to the Final Office Action mailed on September 30, 2003. The period of responds extends to January 30, 2004, with a one-month extension of time. Please enter the following remarks in the above-identified patent application:

Listing of claims begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.